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10/574,202	03/31/2006	Masato Kobayakawa	Q77895	8948	
23.73, 7590 SUGHRUE MION, PLLC 2100 PENNSYL-VANIA AVENUE, N.W.			EXAM	EXAMINER	
			VALENTINE, JAMI M		
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

# Application No. Applicant(s) 10/574,202 KOBAYAKAWA ET AL. Office Action Summary Examiner Art Unit JAMI M. VALENTINE 2815 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS. WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on 15 February 2008. 2a) This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 1-30 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) \_\_\_\_\_ is/are allowed. 6) Claim(s) 1-3 and 6-30 is/are rejected. 7) Claim(s) 4 and 5 is/are objected to. 8) Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) ☐ The drawing(s) filed on 31 March 2006 is/are: a) ☐ accepted or b) ☐ objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some \* c) None of: Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). \* See the attached detailed Office action for a list of the certified copies not received. Attachment(s)

1) Notice of References Cited (PTO-892)

Notice of Draftsperson's Patent Drawing Review (PTO-948)

Information Disclosure Statement(s) (PTO/S5/08)
 Paper No(s)/Mail Date \_\_\_\_\_\_

Interview Summary (PTO-413)
 Paper No(s)/Mail Date.

6) Other:

5) Notice of Informal Patent Application

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## DETAILED ACTION

## Status of the Application

 Acknowledgement is made of the amendment received 2/15/08. Claims 1-6 and 8-30 are pending in this application. Claims 1, 13-17 and 23 were amended and claim 7 was cancelled in the amendment received 2/15/08.

# Response to Arguments

- Applicant's arguments filed 2/15/08 have been fully considered but they are not persuasive.
- 3. Hidemi teaches three barrier layers (layers (6), (8) and (10)) and read on claims 1-3 and 6-12. The labels "A" "C" and "E" are labels and do not distinguish over Hidemi regardless of arbitrary labeling. While product-by-process claims are limited by and defined by the process, determination of patentability is based on the product itself. In re Hirao, 190 USPQ 15 at 17(footnote 3). The patentability of a product does not depend on its method of production. If the product in the product-by-process claim is the same as or obvious from a product of the prior art, the claim is unpatentable even though the prior product was made by a different process. Also if there are structural differences resulting from the claimed process those differences must be specifically claimed to distinguish over otherwise anticipating prior art. Presently there are no specific and different structures claimed, only alleged in the remarks.
- Additionally, Hidemi teaches forming the barrier layer at an increasing temperature [0048] as detailed in the rejection of claim 23.

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 Applicant states that "novelty and inventive step of claim 23 were approved in the International Search Report (ISR)" Applicant is reminded that this national stage application must comply with 35 USC 101, 102 and 112 in order to receive a United States patent.

#### Specification

 The objection to the specification has been withdrawn in light of the amendment received 2/15/08.

# Claim Objections

 The objection to the claims has been withdrawn in light of the amendment received 2/15/08.

# Claim Rejections - 35 USC § 112

- The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- Claim 16 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.
- 10. The following language is indefinite: "wherein a layer with a lower concentration of said n-type dopant is an undoped layer". If the layer has a concentration of dopant then it cannot be considered to be undoped. Where applicant acts as his or her own lexicographer to specifically define a term of a claim contrary to its ordinary meaning, the written description must clearly redefine the claim term and set forth the uncommon definition so as to put one reasonably skilled in the art on notice that the applicant intended to so redefine that claim term. Process Control

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Corp. v. HydReclaim Corp., 190 F.3d 1350, 1357, 52 USPQ2d 1029, 1033 (Fed. Cir. 1999). The term "an undoped layer" in claim 16 is used by the claim to mean "a layer with a lower concentration of said n-type dopant", while the accepted meaning is "a layer with a no dopant concentration".

# Claim Rejections - 35 USC § 102

11. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 12. Claims 1-3 and 6-12, 15-17, 19-21 and 23-29 are rejected under 35 U.S.C. 102(b) as being anticipated by Hidemi et al. (Japanese Patent Application Publication No 2002/043618) hereinafter referred to as Hidemi.
- 13. Per Claims 1 Hidemi (e.g. figure 1) discloses a nitride semiconductor device, comprising
  - an n-type layer (3), a light-emitting layer (4)-(10), and a p-type layer (11) whichare formed of a nitride semiconductor and sequentially stacked on a substrate in the above order, (see figure 1, and [0027]).
  - said light-emitting layer having a quantum well structure in which a well layer (5), (7)
     and (9) is sandwiched by barrier layers (6), (8) and (10) having band gaps wider than the
     band gap of the well layer, [0013]
  - wherein said barrier layers individually comprise a barrier sublayer C (8), a barrier sublayer E (10)

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 and where said barrier sublayer C (8) is disposed closer to said substrate with respect to said barrier sublayer E (10). See translated abstract.

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- 14. Further, claim 1 recites "product-by-process" limitations (i.e. the growth temperatures). While product-by-process claims are limited by and defined by the process, determination of patentability is based on the product itself. In re Hirao, 190 USPQ 15 at 17(footnote 3). The patentability of a product does not depend on its method of production. If the product in the product-by-process claim is the same as or obvious from a product of the prior art, the claim is unpatentable even though the prior product was made by a different process. *In re Thorpe*, 777 F.2d 695, 698, 227 USPQ 964, 966 (Fed. Cir. 1985) See also in re Brown, 173 USPQ 685: In re Luck, 177 USPQ 523; In re Fessmann, 180 USPQ 324: In re Avery, 186 USPQ 116 in re Wertheim, 191 USPQ 90 (209 USPQ 254 does not deal with this issue); and In re Marosi et al, 218 USPQ 289 final product per se which must be determined in a "product by, all of" claim, and not the patentability of the process, and that an old or obvious product, whether claimed in "product by process" claims or not. Note that Applicant has the burden of proof in such cases, as the above case law makes clear.
- 15. Per Claim 2, Hidemi [0033] discloses the device of claim 1, including where the nitride semiconductor is represented by formula  $\ln_{Y} A \ln_{Y} G a_{1,x,y} N$  ( $0 \le x \le 1, 0 \le y \le 1, 0 \le x + y \le 1$ ).
- 16. Per Claims 3 and 6-9, Hidemi discloses the device of claim 1, including barrier layers and barrier sublayers. Claims 3-9 recite "product-by-process" limitations. While product-by-process claims are limited by and defined by the process, determination of patentability is based on the product itself. In re Hirao, 190 USPQ 15 at 17(footnote 3). The patentability of a product does not depend on its method of production. If the product in the product-by-process claim is

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the same as or obvious from a product of the prior art, the claim is unpatentable even though the prior product was made by a different process. *In re Thorpe*, 777 F.2d 695, 698, 227 USPQ 964, 966 (Fed. Cir. 1985) See also in re Brown, 173 USPQ 685: In re Luck, 177 USPQ 523; In re Fessmann, 180 USPQ 324: In re Avery, 186 USPQ 116 in re Wertheim, 191 USPQ 90 (209 USPQ 254 does not deal with this issue); and In re Marosi et al, 218 USPQ 289 final product per se which must be determined in a "product by, all of" claim, and not the patentability of the process, and that an old or obvious product, whether claimed in "product by process" claims or not. Note that Applicant has the burden of proof in such cases, as the above case law makes clear.

- Per Claim 10, Hidemi discloses the device of claim 2, including where said well layer comprises GalnN. [0028]
- Per Claim 11, Hidemi discloses the device of claim 2, including where said barrier layer
   comprises GaInN or GaN. [0033]
- Per Claim 12, Hidemi discloses the device of claim 1, including where at least one layer selected from said well layer and said barrier layer contains an n-type dopant. [0043]
- Per Claim 15, Hidemi discloses the device of claim 12, including where a concentration
  of said n-type dopant in the layer containing said n-type dopant varies periodically. [0033]
- 21. Per Claim 16, Insofar as definite, the claim is interpreted in view of the existing prior art as follows: Hidemi discloses the device of claim 15, including where an "undoped" layer has a lower concentration of said n-type dopant, in the layer containing said n-type dopant. [0069]

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Per Claim 17, Hidemi discloses the device of claim 15, including where a layer with a
higher concentration of said n-type dopant is not thicker than a layer with a lower concentration
of said n-type dopant. [0069]

- 23. Per Claim 19, Hidemi discloses the device of claim 1, including a negative electrode provided on an n-type layer of said nitride semiconductor product and a positive electrode provided on a p-type layer of said nitride semiconductor product. (e.g. figure 1)
- Per Claim 20, Hidemi discloses a light-emitting diode comprising a nitride semiconductor product according to claim 1. [0098]
- Per Claim 21, Hidemi discloses a laser device comprising a nitride semiconductor product according to claim 1. [0098]
- 26. Per Claim 23 Hidemi discloses a method for producing a nitride semiconductor product, said method comprising sequentially stacking on a substrate (1) a nitride semiconductor n-type layer (3), a nitride semiconductor light-emitting layer of a quantum well structure (layers (4)-(10)), and a nitride semiconductor p-type layer (11), thereby producing a nitride semiconductor product having a quantum well structure (see figure 1), wherein said method comprises
  - growing a well layer (5);
  - · subsequently, elevating a growth temperature [0048];
  - growing a barrier layer (barrier layer A, part of (6)) of the quantum well structure at the elevated temperature, which is higher than a growth temperature of the well layer by 50°C or more [0048]
  - subsequently, lowering the growth temperature again by 50°C or more

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further growing the barrier layer (barrier layer B, part of (6)) at the lowered temperature.
 [0048]

- Per Claim 24 Hidemi discloses the method of claim 23 including growing said barrier layer before elevating the growth temperature. [0048]
- Per Claim 25 Hidemi discloses the method of claim 23 including growing of said barrier
   layer is performed in the step of elevating the growth temperature. [0048]
- Per Claim 26 Hidemi discloses the method of claim 23 including where said barrier layer
   (4) contains an n-type dopant. [0046]
- 30. Per Claim 27 Hidemi discloses a method of producing a nitride semiconductor lightemitting device said method comprising a step of removing a portion of a light-emitting layer and a p-type layer of a nitride semiconductor product according to claim 1, thereby exposing an n-type layer, a step of providing a negative electrode on the exposed n-type layer, and a step of providing a positive electrode on the p-type layer. [0088]
- 31. Per Claim 28 Hidemi discloses a method for producing a light-emitting diode, comprising a step of providing a lead to a nitride semiconductor light-emitting device according to claim 19.
- 32. Per Claim 29 Hidemi discloses a method including a step of providing a lead to a nitride semiconductor light-emitting device according to claim 19. This limitation is implicitly disclosed in paragraph [0098]

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all
obviousness rejections set forth in this Office action:

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(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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- 34. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- Claims 13-14 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over
   Hidemi
- 36. Per Claims 13 and 14 Hidemi teaches the device of claim 12, but fails to teach where the said n-type dopant is Si or Ge.
- 37. It would have been obvious to one of ordinary skill in the art at the time the invention was made to use Si or Ge as the dopant, since it has been held to be within the general skill of a worker in the art to select a known material on the basis of its suitability for its intended use as a matter of design choice. In re Leshin, 125 USPO 416.
- 38. Per Claim 18 Hidemi teaches the device of claim 12, but fails to teach where the layer containing said n-type dopant has an n-type dopant concentration of 1x10<sup>16</sup> to 5x10<sup>19</sup> cm<sup>-3</sup>
- 39. It would have been obvious to one of ordinary skill in the art at the time the invention was made to use a material with an n-type dopant concentration of  $1 \times 10^{16}$  to  $5 \times 10^{19}$  cm<sup>-3</sup>, since it has been held to be within the general skill of a worker in the art to select a known material on

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the basis of its suitability for its intended use as a matter of design choice. *In re Leshin,* 125 USPQ 416.

- Claims 22 and 30 are rejected under 35 U.S.C. 103(a) as being unpatentable over
   Hidemi in view of Shimizu et al. (US Patent Application Publication No 2002/0070681),
   hereinafter referred to as Shimizu.
- 41. Per Claim 22 Hidemi discloses the device of claim 1, but fails to teach a lamp.
- 42. Shimizu teaches with a semiconductor light-emitting device. (Figure 1 and [0053])
- 43. It would have been obvious to one having ordinary skill in the art at the time the invention was made to make a lamp as taught by Shimizu with the nitride semiconductor light-emitting device of to claim 1 taught by Hidemi in order to provide an LED lamp with good color reproducibility and high luminous efficacy (Shimizu [0007])
- 44. Per Claim 30, Hidemi discloses the device of claim 19, but fails to teach a method for producing a lamp, comprising a step of providing a cover containing a phosphor to a nitride semiconductor light-emitting device according to claim 19.
- Shimizu teaches a lamp produced by a method including the step of providing a cover containing a phosphor to a semiconductor light-emitting device. (Figure 1 and [0053])
- 46. It would have been obvious to one having ordinary skill in the art at the time the invention was made to make a lamp produced by a method including the step of providing a cover containing a phosphor as taught by Shimizu to the nitride semiconductor light-emitting device according to claim 19 taught by Hidemi in order to provide an LED lamp with good color reproducibility and high luminous efficacy (Shimizu [0007])

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# Allowable Subject Matter

47. Claims 4 and 5 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

#### Conclusion

48. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jami M. Valentine, Ph.D. whose telephone number is (571) 272-9786. The examiner can normally be reached on Mon-Thurs 9:00am-6pm EST.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Kenneth Parker can be reached on (571) 272-2298. The fax phone number for the

organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

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information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Jerome Jackson Jr./ Primary Examiner, Art Unit 2815

Filliary Examiner, A

Jami M Valentine, Ph.D. Examiner Art Unit 2815

/JMV/